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(54) Photoinduced refractive index change in hydrogenated germano-silicate waveguide

Photoinduzierte Brechzahländerung in hydriertem Germaniumsilikat-Wellenleiter

Change de l'indice de réfraction induit par la lumière dans un guide d'ondes germanosilicate hydrogéné

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• ELECTRONICS LETTERS, vol. 20, no. 4, 16 February 1984, Stevenage, GB, pp 182-183; BIBBY et al.
• APPLIED PHYSICS LETTERS, vol. 58, no. 17, 29 April 1991, New York, US, pp 1813-1815; OUELLETTE et al.
• SPIE vol. 1314, 1990, Bellingham, US, pp 223-233; MCSTAY

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Description

Field of the Invention

This invention pertains to a method of making an article that comprises an optical component, e.g., a planar waveguide. More particularly, it pertains to a method that comprises locally changing the refractive index of an oxide glass body. It also pertains to articles made by the method.

Background of the Invention

In-line optical fiber refractive index gratings are known. See, for instance, U.S. patent 4,807,950. See also, U.S. patent 4,725,110, which claims a method of producing such a grating. The currently preferred method of "writing" an in-line grating into optical fiber comprises interference between two beams of actinic (typically UV) radiation in a portion of the fiber. The two beams are incident on the fiber in a transverse direction, the angle between the two beams (and the wavelength of the radiation) defining the grating spacing.

Typically fiber gratings are formed in Ge-doped fiber. See, for instance, F. Ouellette et al., Applied Physics Letters, Vol. 58(17), p. 1813 which inter alia discloses that the sensitivity of the Ge-doped fiber to actinic radiation can be enhanced by a thermal hydrogen treatment (4 hours at 400°C in 12 atmospheres of H₂). See also G. Meltz et al., SPIE, Vol. 1516, International Workshop on Photoinduced Self-Organization in Optical Fiber, May 10-11, 1991, Quebec City, Canada, paper 1516-18, which reports treating a heavily-doped germanosilicate preform rod for 75 hours at 610°C in 1 atmosphere of H₂ to enhance the photosensitivity of the glass. U.S. patent application 643,886, filed January 18, 1991 for R. M. Atkins et al., discloses a process of manufacturing optical fiber that enhances the GeO/GeO₂ ratio in the Ge-doped core of the fiber, thereby enhancing the sensitivity of the fiber to actinic radiation. The process involves, exemplarily, collapsing the preform tube in a substantially oxygen-free atmosphere.

The prior art H₂ sensitization treatments involve exposure of the glass to H₂ at a relatively high temperature, typically at least 400°C. This high temperature treatment would at best be inconvenient if applied to optical fiber. As is well known, optical fiber typically is coated with a polymer material as part of the draw process, since uncoated fiber is fragile and rapidly loses its strength, especially if handled. At the temperature of the prior art H₂ treatments, typical polymer fiber coatings would be destroyed or at least severely damaged. Furthermore, the prior art high temperature sensitization treatment frequently increases the optical loss in the fiber and/or may weaken the fiber.

D. McStay, SPIE, Vol. 1314, "Fibre Optics '90", pp. 223-233, inter alia reports exposing Ge-doped optical fiber to H₂ for various times at various temperatures and

pressures, exemplarily 3 days at 24°C and 1 atmosphere. Raman measurements were interpreted to reveal the presence of molecular hydrogen in the fiber after the exemplary treatment. Exposure of the fiber to 488 nm radiation resulted in increase of a Raman peak at about 2150 cm⁻¹. The peak appeared even if irradiation was delayed until after essentially all of the H₂ had again been lost from the fiber. The author disclosed that the observed photosensitive reaction was a weak one, and suggested that a two-photon process may be involved. No refractive index change was observed.

In view of the potential advantages offered by, e.g., in-line refractive index gratings in optical waveguides, it would be highly desirable to have available a method of locally increasing a waveguide refractive index that is free of the above-discussed shortcomings of the prior art. Furthermore, it would be very desirable if strong in-line gratings could be written into optical fiber of the type conventionally manufactured and installed for optical fiber communication systems, or if an optical waveguide could be "written" into a planar glass layer. This application discloses a method that has these and other advantageous features.

Glossary

An "optical waveguide" herein is a, typically elongate, structure that comprises a "core" of relatively high refractive index glass that is at least partially surrounded by a "cladding" of relatively low refractive index material, and that is adapted for transmitting therethrough (typically in the longitudinal direction) electromagnetic radiation of "optical" wavelength, exemplarily in the range 0.4-1.7 μm.

Summary of the Invention

The invention is defined by the claims. We have introduced relatively large quantities of molecular hydrogen (H₂) into high-silica glass (exemplarily more than 50 or 80 mole percent SiO₂) at quite low temperatures (at most 250°C, but preferably below 150 or even 100°C) and moderate pressures (H₂ partial pressure greater than 1 atmosphere, preferably greater than 10 atmospheres), and have made the quite unexpected discovery that irradiation of the H₂-containing glass with actinic ultraviolet radiation can increase the refractive index of the glass in the irradiated region by an unprecedentedly large amount. Exemplarily the normalized index changes ($\Delta = \Delta n/n$) are at least 10⁻⁵, but preferably are at least 5 × 10⁻⁵ or 10⁻⁴, and can be even larger than 10⁻³. The changes can persist substantially indefinitely if the glass is not heated, with at least a significant fraction of the change surviving moderate heating (e.g., ≤ 400°C) of the glass. Index changes of less than 10⁻⁵ can of course be produced but are typically not commercially useful.

The invention relates to a method of making an ar-

title that comprises an optical component, (e.g., an optical fiber, a planar waveguide or a phase mask) and, in one exemplary embodiment, comprises providing the waveguide, exposing the waveguide to H_2 and irradiating at least a portion of the waveguide with actinic radiation such that the refractive index of the irradiated portion is changed. Significantly, during the H_2 -exposure step the waveguide is at a temperature of at most $250^\circ C$. The waveguide is exposed to a H_2 -containing atmosphere that has a H_2 partial pressure of at least 1 atmosphere, and the resulting normalized index change is at least about 10^{-5} , and preferably is at least 5×10^{-5} or 10^{-4} . By "hydrogen" or " H_2 " we mean herein hydrogen and/or its isotope deuterium.

In another exemplary embodiment the invention comprises exposing a body that comprises high-silica glass to hydrogen in substantially the above described manner, followed by exposure of the glass to actinic ultraviolet radiation such that the refractive index in a predetermined region of the glass is raised by an appropriate amount, exemplarily such that the core of a planar waveguide is formed.

The inventive method can be used in a variety of ways. For instance, it can be used to make in-line refractive index gratings in optical fiber or in planar waveguides, or it can be used to produce a substantially uniform index change in a portion of an optical fiber or planar waveguide. It can also be used to "write" the core of a planar optical waveguide into appropriate glass, and to pattern the refractive index of an appropriate glass body such that, e.g., a hologram or phase mask results.

Brief Description of the Drawings

FIG. 1 presents exemplary data on UV-induced refractive index change as a function of H_2 concentration in the glass;

FIG. 2 shows exemplary data on refractive index as a function of time during the course of a particular heat treatment of an optical fiber,

FIG. 3 schematically depicts a novel planar optical waveguide; and

FIG. 4 shows schematically the refractive index vs. radius of an exemplary optical fiber with an in-line index grating; and

FIGS. 5 and 6 schematically show other exemplary articles according to the invention, namely, a hologram and a phase mask, respectively.

Detailed Description of Some Preferred Embodiments

Exemplary of the novel hydrogen treatment is the following. Three samples of standard, commercially available, optical communications fiber (namely, AT&T's 5D fiber which has a germanosilicate core, with about 2.6 mole % GeO_2 , and which, absent a sensitization treatment, exhibits no significant photosensitivity; ex-

emplarily $\Delta \approx 10^{-5}$) were maintained at $75^\circ C$ for periods of 48-72 hours in a hydrogen atmosphere at 10.4, 42 and 147 atmospheres. The resulting H_2 -concentrations in the fiber core were calculated to be, respectively, 6.98×10^2 , 2.82×10^3 , and 9.84×10^3 parts per million (ppm; 1 ppm is defined as 10^{-6} moles H_2 per mole of SiO_2). Exposure of the thus prepared fibers to UV radiation (about 242 nm) from an excimer pumped, frequency doubled dye laser (20 pulses/second, 2mJ/pulse, 10 minutes exposure) resulted, respectively, in the following normalized index changes $\Delta(\Delta = \Delta n/n)$: 9.7×10^{-5} , 7×10^{-4} , and 1.8×10^{-3} . Increasing the exposure to the actinic radiation would not have substantially further increased Δ .

Another commercially available optical fiber (having about 10 mole % GeO_2 in the core), was maintained at $50^\circ C$ in 95 atmospheres of H_2 for 3 days resulting in about 8.04×10^3 ppm H_2 in the fiber core. Exposure (1.5mJ/pulse, 50 pulses/second, 8 minutes) to the above-described UV radiation resulted in $\Delta = 1.6 \times 10^{-3}$.

These exemplary results are shown in FIG. 1, wherein points 11, 12 and 13 pertain to the lightly Ge-doped (5D) fiber, and 14 pertains to the moderately Ge-doped fiber. As FIG. 1 illustrates, there appears to exist a substantially linear relationship between H_2 content in the fiber and the attainable value of index change, at least for some range of Ge-doping.

Although some useful index change may be obtainable also for very low levels of Ge-doping (e.g., <0.5 mole % of GeO_2), the invention will frequently be embodied in silica glass (i.e., oxide glass in which SiO_2 is the largest single constituent) comprising at least 0.5 mole % GeO_2 or other appropriate dopant, or in germania glass (i.e., in oxide glass in which GeO_2 is the largest single constituent; including pure vitreous germania). Pure SiO_2 does not exhibit any significant index change, substantially independent of the H_2 concentration in the fiber (at least up to about 8,400 ppm H_2). We currently believe that the invention can be embodied in many oxide glasses that comprise GeO_2 , or that comprise SiO_2 and GeO_2 or other appropriate dopant. One of ordinary skill in the art generally will be able to determine, with only a modest experimental effort, whether an oxide glass of a given composition is suitable for the practice of the invention.

Other exemplary results are as follows: maintaining an optical fiber at $200^\circ C$ for 40 minutes in 150 atmospheres of H_2 results in about 4.56×10^3 ppm of H_2 in the core. And maintaining a planar structure comprising a 251 μm thick layer of SiO_2 , with an underlying germanosilicate glass layer (8 μm thick, 2.6 mole % GeO_2) at $21^\circ C$ for 6 days in 187 atmospheres H_2 , or at $75^\circ C$ for 11 hours at 325 atmospheres H_2 , is estimated to result in sufficient H_2 loading to generate a waveguide core in the germania-doped glass with $\Delta \sim 4 \times 10^{-3}$, after exposure to UV radiation.

We currently believe that the prior art (high temperature) hydrogen treatment involves a different physical

mechanism than does the inventive (low temperature) treatment. The experimental facts disclosed by McStay (op. cit.) also clearly show that the weak photosensitivity observed by him is due to a different mechanism than the large photorefractive effect that can result from a treatment according to the invention.

It will be appreciated that, after completion of loading the glass with H_2 , some of the hydrogen will generally again diffuse out of the glass, at a rate that depends inter alia on temperature. However, the rate typically is slow enough such that there is ample time (typically many hours) to irradiate the glass with actinic radiation. Exemplarily, irradiation should take place within about one week from the completion of the hydrogen loading. Those skilled in the art will recognize the cold storage of the fiber will retard out-diffusion, making longer delays possible.

Loss of H_2 from the unirradiated portions of the glass has the desirable consequence that the inventive method results in relatively little increase of the optical loss in the waveguide, and in substantially no change in refractive index in the unirradiated portions.

The question of reliability of index gratings in fiber is of concern to those involved in the development of such gratings. By this we mean that there is concern in the field whether or not the properties (e.g., optical strength) of such gratings will change with time, especially if a grating is exposed to elevated temperatures. Similar considerations apply to other articles according to the invention.

The inventive method can result in highly stable refractive index change, as is exemplarily illustrated by FIG. 2, which shows the normalized refractive index change Δ as a function of time, for an exemplary commercially available (5D) fiber that had previously been loaded with H_2 and exposed to UV radiation such that a refractive index grating (spacing about $0.5 \mu m$) was formed in the fiber. The fiber contained about 9.3×10^3 ppm H_2 but the UV exposure was limited such that a grating of moderate strength ($\Delta \sim 1.1 \times 10^{-4}$) resulted. After the grating was fully formed the fiber was heated to $750^\circ C$ at $250^\circ C/hour$, followed by cooling to room temperature. As can be seen from FIG. 2, after reaching $750^\circ C$ the normalized index change had decreased to about 3×10^{-5} . About 19 hours after the start of the temperature treatment the fiber was heated to $500^\circ C$ and maintained at that temperature for about 29 hours. As can be seen from FIG. 2, the refractive index remained essentially constant during this time, indicating that the previous annealing had eliminated relatively unstable species, with the remaining species being stable even at the very high temperature of $500^\circ C$.

The inventive method optionally comprises an anneal that results in substantial elimination of relatively unstable species, whereby the reliability of the index change in the fiber can be improved. Generally, the anneal involves heating of the waveguide (or of a relevant portion thereof, e.g., substantially only the waveguide

core) to a temperature above any anticipated operating temperature of the waveguide. This heating can take place during exposure to actinic radiation, or subsequent thereto. It can also take place subsequent to a first and prior to a second exposure. A preferred method of heating substantially only the waveguide core comprises coupling into the waveguide radiation of a wavelength at which the UV irradiated portion of the waveguide absorbs, e.g., at about $1.4 \mu m$ for H_2 -treated fiber. It will be appreciated that by "heating" in this context we mean heating for a period of time (exemplarily at least a minute) that is effective for removing at least a major portion of the defects that are not stable at the anneal temperature. The term does not include any transitory heating that may be associated with the incidence of an individual pulse of the actinic radiation.

As those skilled in the art will recognize, annealing results in a (typically temperature-dependent) decrease in Δ , requiring that the initial Δ be larger than the desired. It is a simple matter to determine, for a predetermined anneal temperature, the fractional decrease in Δ , and therefore it is a simple matter to determine the appropriate initial Δ , or equivalently, the appropriate H_2 loading conditions. In many cases waveguide operating temperatures will not exceed $75^\circ C$, and anneal temperatures will frequently be in the range 200 - $400^\circ C$, (but always higher than the anticipated maximum operating temperature, frequently at least $100^\circ C$ higher).

As those skilled in the art will appreciate, the inventive method can be used to modify the refractive index not only of optical fiber but also of planar waveguides. Furthermore, the method's ability to readily yield large refractive index changes (e.g., $\Delta n > 10^{-4}$) makes possible a novel method of forming optical components, e.g., planar optical waveguides, as schematically depicted in FIG. 3. Exemplarily, on substrate 30 (e.g., a Si or SiO_2 wafer) is formed lower cladding layer 31 (e.g., vitreous silica), doped silica (e.g., germanosilicate) layer 32, and upper cladding layer 33 (e.g., vitreous silica). This structure (37) has waveguiding properties normal to the layers, but does not confine the radiation in the plane. Confinement is achieved by loading the structure with H_2 , substantially as described above, irradiating the structure with focused actinic radiation 34, and moving the beam over the structure in a predetermined manner (indicated by arrow 35). (Alternatively, a mask can be used to expose preselected portions.) The refractive index in core region 35 is raised, providing lateral guiding. On the other hand, the index of layers 31 and 33 remains essentially unchanged. It will be appreciated that layers 31 and 33 are optional and that layer 33 can be deposited after exposure of 32 to actinic radiation.

As will be evident to those skilled in the art, the described novel technique for forming planar waveguides has many advantageous features. For instance, it can be used to readily make any desired waveguide configuration without need for SiO_2 etching, retaining surface planarity. Importantly, waveguides according to the in-

vention are embedded in structurally homogeneous material and thus are likely to have relatively low scattering loss.

The inventive method can be embodied in a variety of articles, including optical fiber communications systems, and fiber or planar optical amplifiers. It can also be embodied in optical fiber that has a novel combination of properties, namely a relatively lightly doped core (typically less than 4.5 mole % GeO_2 per mole of SiO_2) and relatively large localized index variations (typically Δ at least 10^{-4}). The refractive index of such a fiber is schematically depicted in FIG. 4, where n_0 refers to the refractive index of pure vitreous silica, n_c and n_1 to the refractive indices of core 40 and cladding 41, respectively. The normalized core/cladding index difference $\Delta = (n_c - n_1)/n_0$, and 421, 422,..... refers to the localized regions of increased refractive index. Exemplarily, the localized variations are periodic, forming a strong in-line grating whose repeat distance Λ is about $0.5\mu\text{m}$, and typically (although not necessarily), is less than about $100\mu\text{m}$. It will of course be understood that the refractive index profile in actual optical fiber is not as regular as the schematic profile of FIG. 4, and that actual profiles do not have such sharp transitions between the various regions. However, actual profiles are frequently described in terms of conventional equivalent step index profile (having effective indices and effective radii). Thus, FIG. 4 is meant to show the equivalent step index profile, and n and n_1 are intended to be effective refractive indices. It will also be understood that the above discussion refers only to fiber that has axially uniform cross section (i.e., excluding fiber that has been treated to comprise a periodic change of the cross section), and furthermore refers only to fiber wherein the cladding refractive index is substantially unchanged.

As disclosed above, the inventive method can advantageously be used to pattern the refractive index of appropriate oxide glass. This approach was used to make a planar optical waveguide as follows. A glass body (3 mole % GeO_2 , remainder SiO_2 ; $25 \times 10 \times 2$ mm) was maintained 308 hours at 21°C in 208 atmospheres H_2 , resulting in 2.4 mole % H_2 concentration at the sample surface, and about 1.1 mole % H_2 at $50\mu\text{m}$ depth. A beam of UV radiation (242 nm wavelength, 1.5 mJ/pulse, 30 pulses/s) was brought to a (about $100\mu\text{m}$ wide) line focus, and the focused beam scanned across the width of one of the 25×10 mm faces of the glass bodies at the rate of $60\mu\text{m/s}$. Subsequent to UV exposure, light from an argon ion laser (514.5 nm wavelength) was focused on one end of the exposed region by means of a $\times 6$ microscope objective. Waveguiding was verified by observation of the far field pattern of the light emerging from the other end of the exposed region. The pattern, observed at a distance of 119 cm from the exit face, was an elliptical spot (about 60×8 mm), with the long axis of the ellipse being parallel to the normal to the exposed face of the glass body, and the short axis of the ellipse being parallel to the width of the exposed

region. This established that the exposed region formed a (multimode) waveguide, with the depth of the guide being less than the width. A single mode waveguide can readily be made by a similar process.

FIG. 5 schematically shows another exemplary article according to the invention, namely, a hologram 50. The article comprises an oxide glass body 51, e.g., a thin plate of Ge-doped vitreous silica, with desired regions 52 of the plate having a higher refractive index than the remainder of the material. The patterned refractive index is produced by appropriate exposure to actinic radiation subsequent to H_2 -loading of the body, in a manner substantially as described. The appropriate refractive index pattern can either be computed and produced by selective exposure of the body to actinic radiation, or it can result from exposure to interfering beams of actinic radiation. Those skilled in the art will appreciate that all of regions 52 need not have the same refractive index, and that the refractive index can vary within any given region 52. Body 50 can advantageously be used, e.g., for information storage.

FIG. 6 schematically depicts a particular and currently preferred embodiment of the article of FIG. 5, namely, a phase mask 60 that can be used to, e.g., produce an in-line refractive index grating in an optical waveguide, substantially as described in co-assigned U. S. patent application Serial No. 08/004,770. Appropriately uniformly doped high silica glass plate 61 comprises spaced apart regions 62 of increased refractive index, relative to regions 63. Regions 62 thus have greater optical thickness than regions 63, with light that is transmitted through a region 62 in general being phase shifted relative to light transmitted through a region 63. The increase in refractive index is advantageously obtained by exposure to actinic radiation subsequent to H_2 -loading as described. It will be appreciated that the index profile can be readily tailored as desired by, e.g., appropriate choice of exposure conditions.

Loading oxide glass with H_2 (or D_2) as described above, followed by exposure to actinic radiation, results in the presence of OH (OD) in the exposed regions of the glass, with the OH (OD) level typically being substantially proportional to the index change in the region. Thus, the presence in the glass of regions of relatively high and relatively low OH (OD) concentration typically is a feature of our invention. For instance, a normalized refractive index change $\Delta = 2 \times 10^{-4}$ is associated with about 2000 ppm of OH, and, equivalently, with a loss at $1.39\mu\text{m}$ (the first OH overtone) of about 0.3 dB/cm, and $\Delta = 2 \times 10^{-2}$ is associated with about 20 mole % OH and a loss at $1.39\mu\text{m}$ of about 30 dB/cm. Exemplarily, optical components according to the invention will comprise high-silica glass containing a region of relatively high OH (OD)-content, and therefore relatively high (e.g., $> 0.1\text{ dB/cm}$ of grating, at $1.39\mu\text{m}$ for OH) optical loss, as well as a region of relatively low OH (OD) content, and therefore relatively low (e.g., $< 0.1\text{ dB/cm}$, at $1.39\mu\text{m}$ for OH, typically < 0.01 or even 0.001 dB/cm) optical loss.

• As those skilled in the art will appreciate, if the glass is sensitized with D_2 instead of H_2 then the relevant wavelength (the first OD overtone) is about $1.9\mu m$. In some optical fibers loss measurements at $1.9\mu m$ might be difficult, and measurement at $1.26\mu m$ (the second OD overtone) might be preferable, despite the fact that absorption at the second overtone is much weaker than at the first. However, whatever overtone wavelength is selected, a grating according to the invention in an optical waveguide will have an optical loss (in dB/cm of grating) due to OD that is at least 10 times the optical loss due to OD (in dB/cm) in the grating-free part of the waveguide.

More generally, articles according to the invention will typically comprise a body that comprises oxide glass that comprises a first and a second region, with the former having a normalized refractive index that is greater than that of the latter by at least 10^{-5} . Furthermore, the glass contains a chemical species selected from OH and OD, with the concentration of said species in at least a part of the first region being at least ten times the concentration of the species in the second region. Aside from the variation in OH or OD, the chemical composition of the glass is essentially the same in said first and second regions. The first region exemplarily is the core of a planar optical waveguide, or a high-index part of an in-line refractive index grating in the core of an optical fiber.

Claims

1. Method of making an article that comprises an optical component, the method comprising making the optical component by a process that comprises

- a) providing an oxide glass
- b) contacting the oxide glass with an atmosphere comprising a sensitizing gas; and
- c) exposing a first portion of the oxide glass to actinic ultraviolet radiation such that the refractive index of said first portion of the oxide glass is increased above the refractive index of an unexposed second portion of the oxide glass, with a normalized refractive index change Δ of at least 1×10^{-5} ;

CHARACTERIZED IN THAT

- d) the oxide glass is an oxide glass body of given shape;
- e) step b) comprises contacting said oxide glass body of given shape at a temperature of at most $250^\circ C$, with the atmosphere having a sensitizing gas partial pressure greater than 10 atmospheres, the sensitizing gas being one or both of H_2 and D_2 ; and
- f) step c) comprises exposing said first portion

of the oxide glass body of given shape to said actinic ultraviolet radiation such that there is formed in said first portion a chemical species selected from the group consisting of OH and OD, with the concentration of said chemical species in said first portion being at least ten times the concentration of said chemical species in the second portion.

2. Method according to claim 1, wherein the atmosphere is essentially D_2 , the temperature is at most $150^\circ C$, and Δ is at least 5×10^{-5} .
3. Method according to any of claims 1-2, wherein the oxide glass is selected from the group consisting of the oxide glasses having SiO_2 as their largest constituent and the oxide glasses having GeO_2 as their largest constituent.
4. Method according to any of claims 1-3, wherein the oxide glass comprises more than 50 mole % SiO_2 , and more than 0.5 mole % GeO_2 .
5. Method according to any of claims 1-4, wherein the optical component is a planar optical wave guide or an optical fiber.
6. Method according to claim 5, wherein the optical waveguide or optical fiber comprises a core that comprises at least 0.5 mole % GeO_2 .
7. Method according to claim 1, wherein associated with the optical component is a maximum anticipated operating temperature, and wherein the method comprises heating, during and/or subsequent to step c), at least a part of the first portion of the oxide glass to a temperature that is greater than the maximum anticipated operating temperature of the component.
8. Method of claim 7, wherein the optical component comprises an optical waveguide including a core, and said core is heated by means of radiation coupled into the waveguide.
9. Method of claim 7, further comprising irradiating at least some of said first portion of the oxide glass with actinic ultraviolet radiation subsequent to said heating step.
10. Method according to claim 1, wherein the article is an optical communication system, and the component is a planar optical waveguide or an optical fiber.
11. Method according to claim 1, wherein the optical component is a hologram or a phase mask.
12. An article comprising a body (e.g., 37) that compris-

es oxide glass, said oxide glass comprising a first region (36) and a second region, with the oxide glass in the first region having a normalized refractive index that is greater than that of the second region, wherein the normalized refractive index in the first region exceeds the normalized refractive index in the second region by at least 10^{-5} ;

CHARACTERIZED IN THAT

said oxide glass contains a chemical species selected from the group consisting of OH and OD, with the concentration of said chemical species in said first region being at least ten times the concentration of the chemical species in the second region.

re im wesentlichen aus D_2 besteht, die Temperatur höchstens 150°C beträgt und Δ mindestens 5×10^{-5} ist.

Patentansprüche

1. Verfahren zur Herstellung eines Gegenstands, der eine optische Komponente umfaßt, wobei das Verfahren beinhaltet, die optische Komponente durch einen Prozeß herzustellen, der folgendes umfaßt:

- a) Bereitstellen eines Oxidglases
- b) das Oxidglas mit einer ein sensibilisierendes Gas enthaltenden Atmosphäre in Berührung zu bringen; und
- c) einen ersten Teil des Oxidglases derart mit aktinischer ultravioletter Strahlung zu belichten, daß der Brechungsindex des ersten Teils des Oxidglases über den Brechungsindex eines unbelichteten zweiten Teils des Oxidglases angehoben wird, mit einer Veränderung des normierten Brechungsindex von mindestens 1×10^{-5} ;

dadurch gekennzeichnet, daß

- d) das Oxidglas ein Oxidglaskörper gegebener Form ist;
- e) Schritt b) umfaßt, den Oxidglaskörper gegebener Form bei einer Temperatur von höchstens 250°C mit der Atmosphäre mit einem Sensibilisiergas-Partialdruck von über 10 Atmosphären in Berührung zu bringen, wobei das sensibilisierende Gas entweder H_2 oder D_2 ist; und
- f) Schritt c) umfaßt, den ersten Teil des Oxidglaskörpers gegebener Form derart mit aktinischer ultravioletter Strahlung zu belichten, daß in dem ersten Teil eine chemische Spezies, ausgewählt aus der Gruppe bestehend aus OH und OD, gebildet wird, wobei die Konzentration der chemischen Spezies in dem ersten Teil mindestens zehnmal so groß ist wie die Konzentration der chemischen Spezies in dem zweiten Teil.

2. Verfahren nach Anspruch 1, bei dem die Atmosphä-

3. Verfahren nach einem der Ansprüche 1-2, bei dem das Oxidglas aus der Gruppe bestehend aus den Oxidgläsern mit SiO_2 als ihrem größten Bestandteil ausgewählt ist und der größte Bestandteil der Oxidgläser GeO_2 ist.
4. Verfahren nach einem der Ansprüche 1-3, bei dem das Oxidglas mehr als 50 Mol-% SiO_2 und mehr als 0,5 Mol-% GeO_2 enthält.
5. Verfahren nach einem der Ansprüche 1-4, bei dem die optische Komponente ein planarer optischer Wellenleiter oder eine optische Faser ist.
6. Verfahren nach Anspruch 5, bei dem der optische Wellenleiter oder die optische Faser einen Kern umfaßt, der mindestens 0,5 Mol-% GeO_2 enthält.
7. Verfahren nach Anspruch 1, bei dem mit der optischen Komponente eine zu erwartende höchste Betriebstemperatur verbunden ist und wobei das Verfahren umfaßt, während und/oder nach Schritt c) den ersten Teil des Oxidglases mindestens teilweise auf eine Temperatur zu erhitzen, die über der zu erwartenden höchsten Betriebstemperatur der Komponente liegt.
8. Verfahren nach Anspruch 7, bei dem die optische Komponente einen optischen Wellenleiter mit einem Kern umfaßt und der Kern mit Hilfe von in den Wellenleiter eingekoppelter Strahlung erhitzt wird.
9. Verfahren nach Anspruch 7, das weiterhin umfaßt, nach dem Erhitzungsschritt den ersten Teil des Oxidglases mindestens teilweise mit aktinischer ultravioletter Strahlung zu bestrahlen.
10. Verfahren nach Anspruch 1, bei dem der Gegenstand ein optisches Kommunikationssystem ist und die Komponente ein planarer optischer Wellenleiter oder eine optische Faser ist.
11. Verfahren nach Anspruch 1, bei dem die optische Komponente ein Hologramm oder eine Phasemaske ist.
12. Gegenstand mit einem Körper (z.B. 37), der aus Oxidglas besteht, wobei das Oxidglas einen ersten Bereich (36) und einen zweiten Bereich umfaßt, wobei das Oxidglas in dem ersten Bereich einen normierten Brechungsindex aufweist, der über dem des zweiten Bereichs liegt, wobei der normierte Brechungsindex im ersten Bereich um mindestens 10^{-5} über dem normierten Brechungsindex im zwei-

ten Bereich liegt, dadurch gekennzeichnet, daß das Oxidglas eine chemische Spezies, ausgewählt aus der Gruppe bestehend aus OH und OD, enthält, wobei die Konzentration der chemischen Spezies in dem ersten Bereich mindestens zehnmal so groß ist wie die Konzentration der chemischen Spezies im zweiten Bereich.

Revendications

1. Procédé de fabrication d'un article comprenant un composant optique, le procédé comprenant la fabrication du composant optique par un processus qui comprend
 - a) la fourniture d'un verre d'oxyde
 - b) la mise en contact du verre d'oxyde avec une atmosphère comprenant un gaz activateur ; et
 - c) l'exposition d'une première partie du verre d'oxyde à un rayonnement actinique ultraviolet de manière à élever l'indice de réfraction de ladite première partie du verre d'oxyde au-dessus de l'indice de réfraction d'une seconde partie non exposée du verre d'oxyde, avec un changement Δ de l'indice de réfraction normalisé de 1×10^{-5} au moins

caractérisé en ce que

 - d) le verre d'oxyde est un corps en verre d'oxyde de forme donnée ;
 - e) l'étape b) comprend la mise en contact dudit corps en verre d'oxyde de forme donnée à une température de 250°C au plus avec une atmosphère ayant une pression partielle du gaz sensible supérieure à 10 atmosphères, le gaz sensible étant du H_2 , du D_2 ou les deux ; et
 - f) l'étape c) comprend l'exposition de ladite première partie du corps en verre d'oxyde de forme donnée audit rayonnement actinique ultraviolet de manière à former dans ladite première partie une espèce chimique sélectionnée dans le groupe composé de OH et de OD avec la concentration de ladite espèce chimique dans ladite première partie d'au moins dix fois la concentration de ladite espèce chimique dans la seconde partie.
2. Procédé selon la revendication 1, dans lequel l'atmosphère est essentiellement du D_2 , la température est de 150°C au plus, et le Δ est de 5×10^{-5} au moins.
3. Procédé selon l'une quelconque des revendications 1 - 2, dans lequel le verre d'oxyde est sélectionné dans le groupe composé des verres d'oxyde ayant le SiO_2 comme constituant principal et des verres d'oxyde ayant le GeO_2 comme constituant principal.
4. Procédé selon l'une quelconque des revendications 1 - 3, dans lequel le verre d'oxyde comprend plus de 50 % en moles de SiO_2 et plus de 0,5 % en moles de GeO_2 .
5. Procédé selon l'une quelconque des revendications 1 - 4, dans lequel le composant optique est un guide d'ondes optique planar ou une fibre optique.
6. Procédé selon la revendication 5, dans lequel le guide d'ondes optique ou la fibre optique comprend un coeur qui comprend au moins 0,5 % en moles de GeO_2 .
7. Procédé selon la revendication 1, dans lequel on associe au composant optique une température de fonctionnement maximum prévue et dans lequel le procédé comprend le chauffage, pendant et/ou consécutif à l'étape c), d'au moins une fraction de la première partie du verre d'oxyde à une température supérieure à la température de fonctionnement maximum prévue du composant.
8. Procédé de la revendication 7, dans lequel le composant optique comprend un guide d'ondes optique comportant un coeur, et ledit coeur est chauffé au moyen de rayonnement couplé vers l'intérieur du guide d'ondes.
9. Procédé de la revendication 7 comprenant de plus l'irradiation d'au moins une fraction de ladite première partie du verre d'oxyde, avec un rayonnement actinique ultraviolet, consécutive à ladite étape de chauffage.
10. Procédé selon la revendication 1, dans lequel l'article est un système de communication optique et le composant est un guide d'ondes optique planar ou une fibre optique.
11. Procédé selon la revendication 1, dans lequel le composant optique est un hologramme ou un masque de phase.
12. Article comprenant un corps (par exemple 37) qui comprend du verre d'oxyde, ledit verre d'oxyde comprenant une première région (36) et une seconde région, le verre d'oxyde de la première région ayant un indice de réfraction normalisé qui est supérieur à celui de la seconde région, l'indice de réfraction normalisé dans la première région étant supérieur à l'indice de réfraction normalisé dans la seconde région d'au moins 10^{-5} ;
caractérisé en ce que
ledit verre d'oxyde contient une espèce chimique

que sélectionnée dans le groupe composé de OH et de OD avec la concentration de ladite espèce chimique dans ladite première région d'au moins dix fois la concentration de ladite espèce chimique dans la seconde région.

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FIG. 1

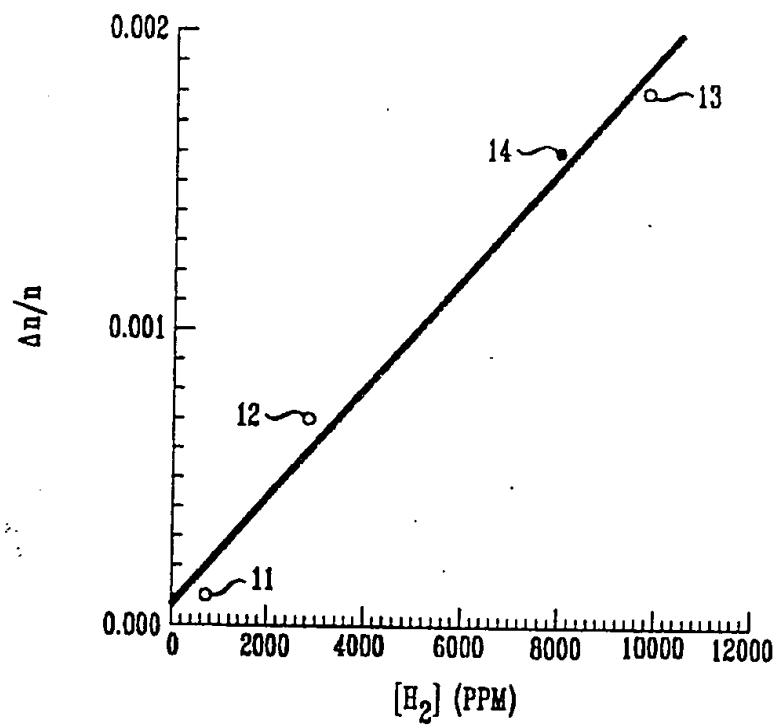


FIG. 2

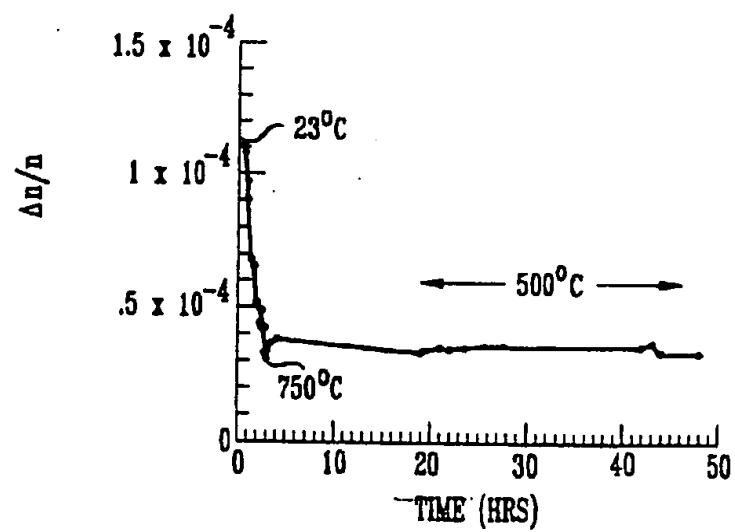


FIG. 3

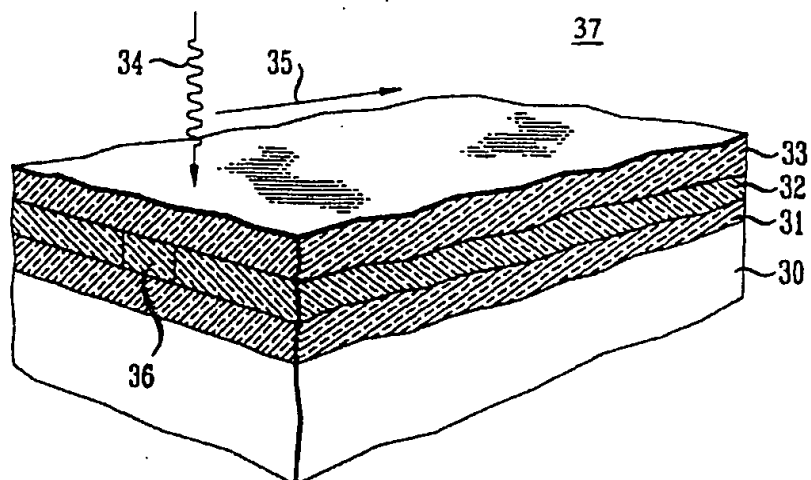


FIG. 4

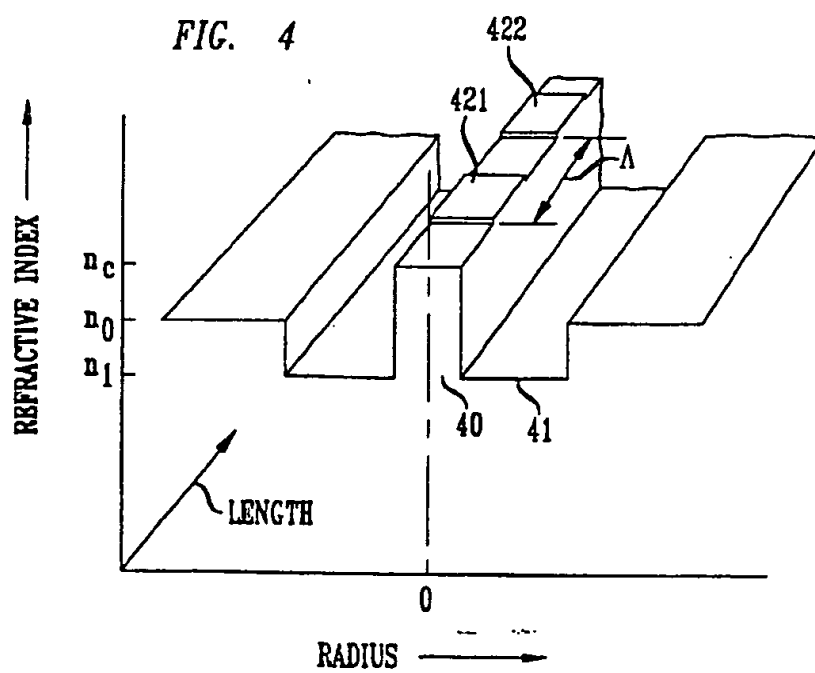


FIG. 5

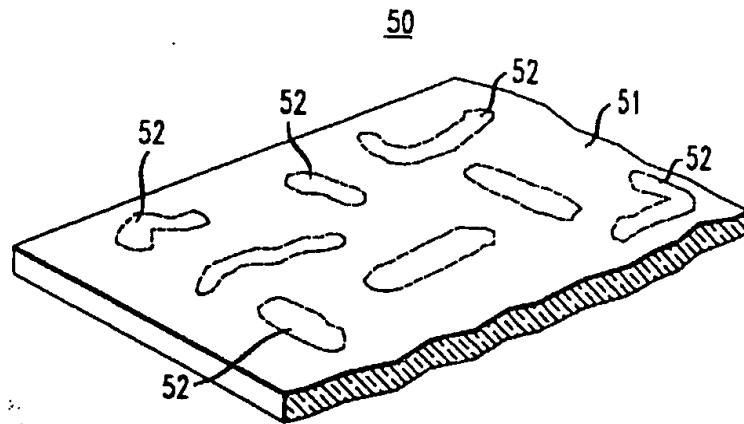


FIG. 6

